

IN THE SPECIFICATION:

Please amend the abstract on page 10 of the application as filed as follows:

[0024] A method for recording a pattern includes: (i) determining an illumination scheme in response to the pattern; and (ii) directing, in response to the determination, at least one beam of radiation having a first cross-section towards [[an]] a saturable absorber such as to allow a portion of ~~said beam~~ the beam to propagate towards a radiation sensitive layer; wherein the portion has a second cross-section that is smaller than the first cross-section.